

**INFORMATION DISCLOSURE CITATION**  
*(Use several sheets if necessary)*

DP-300317

 S.N.O. 3025  
 09/730,508

YAN, ET AL.

FILING

DECEMBER 5, 2000

GROUP

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	3,833,499	09/03/74	EGAN, ET AL.			
	4,151,121	04/24/79	GLADROW			
	4,711,770	12/08/87	SKEELS, ET AL.			
	4,882,307	11/21/89	TSAO			
	4,985,210	01/15/91	MINAMI			
	5,051,244	09/24/91	DUNNE, ET AL.			
	5,078,979	01/07/92	DUNNE			
	5,168,085	12/01/92	ADDIEGO, ET AL.			
	5,179,053	01/12/93	SUBRAMANIAN, ET AL.			
	5,273,945	12/28/93	DES COURIERES, ET AL.			
	5,278,113	01/11/94	ONO, ET AL.			

## FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
					YES	NO

OTHER DOCUMENTS *(Including Author, Title, Date, Pertinent Pages, Etc.)*


EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

## INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

PATENT DOCKET NO.

DP-300317

SERIAL NO.

09/730,508

YAN, ET AL.

FILING

DECEMBER 5, 2000

GROUP

## U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
	5,354,720	10/11/94	LEYRER, ET AL.			
	5,447,694	09/05/95	SWAROOP, ET AL.			
	5,459,119	10/17/95	ABE, ET AL.			
	5,510,086	04/23/96	HEMINGWAY, ET AL.			
	5,531,068	07/02/96	KASS, ET AL.			
	5,662,869	09/02/97	ABE, ET AL.			
	5,772,972	06/30/98	HEPBURN, ET AL.			

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.